

MEMS

design \leftrightarrow technology

Lina Sarro

DIMES

(**D**elft **I**nstitute **M**icrosystems & nano**E**lectronics)

Delft University of Technology



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MEMS:

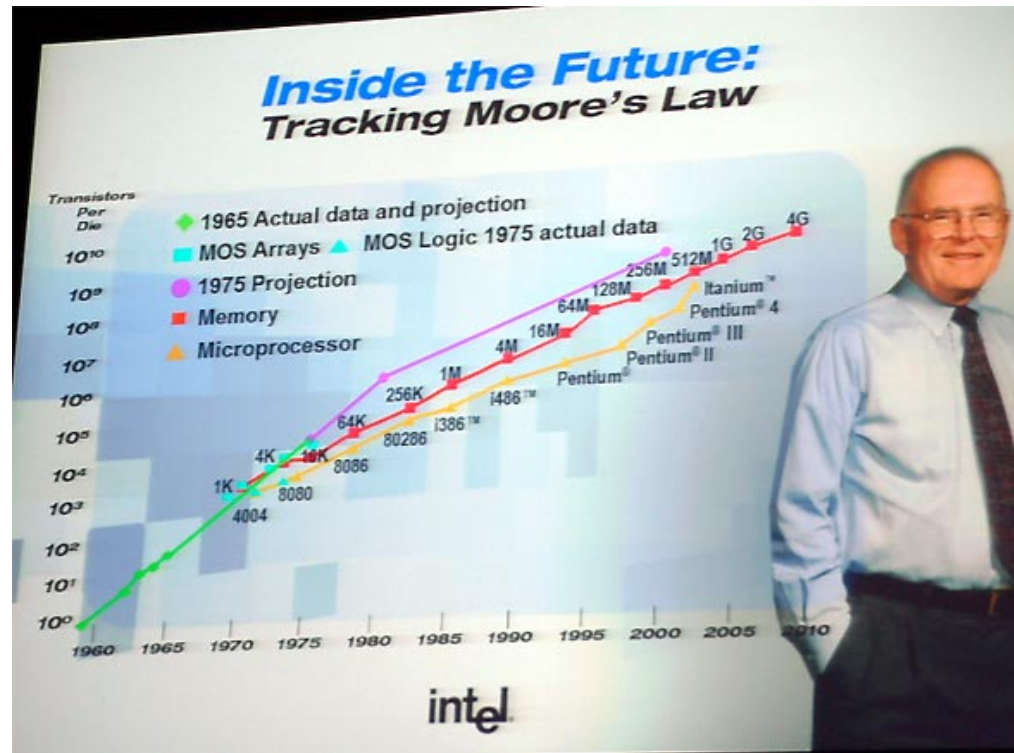
Micro-Electro-Mechanical-Systems

Microsystems employ **miniaturization** to achieve high complexity in a small space

Generally fabricated using modified integrated circuit (IC) fabrication techniques and materials → Si-based

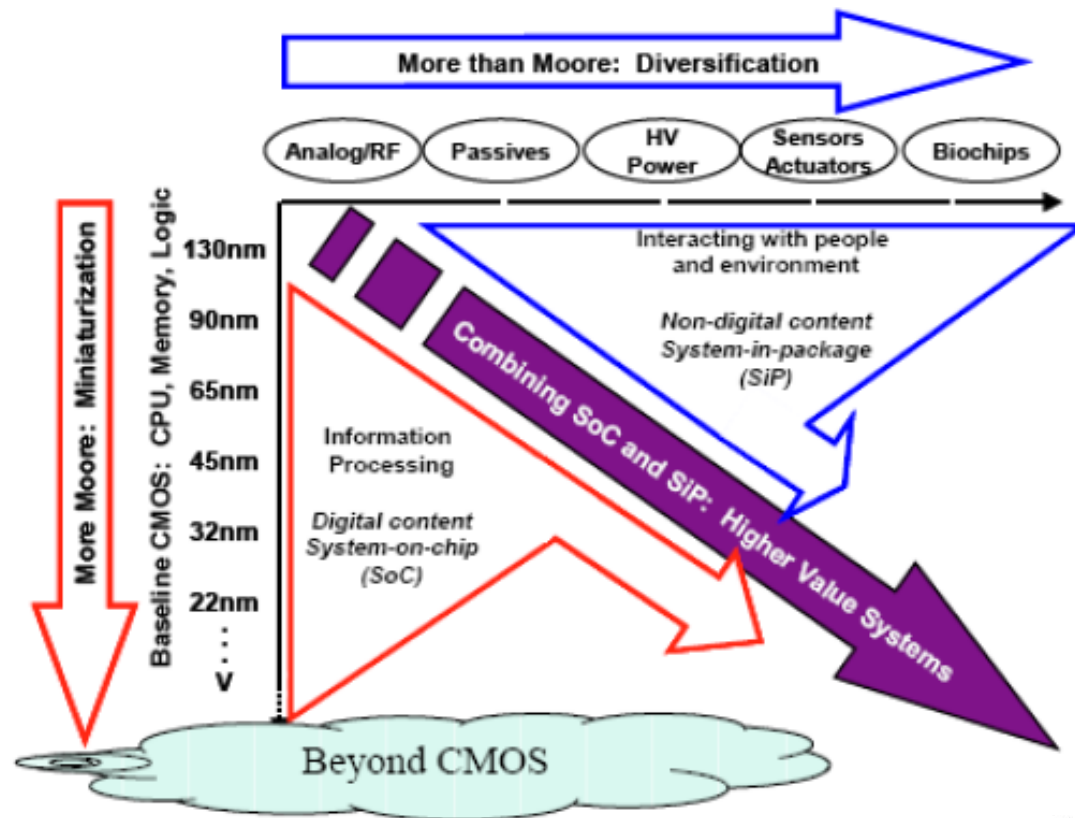
Microelectronics → Moore's Law

*Miniaturization: More **transistors** per chip area*



MEMS → More than Moore

*Miniaturization: More **functions** per chip area*



Generic/Application related Requirements for MEMS

- *High sensitivity/High resolution*
- *Low noise*
- *Stable/robust*
- *Fast response*
- *Small*
- *Low cost*
- *Low power*
- *Non contaminant/non invasive*
- *Non contaminable*
- *Compatible with meso and nanoelectronics*

“Ingredients” for MEMS development

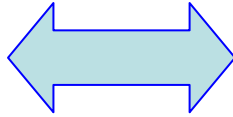
- *Physics, Material science, Chemistry*
- *Technological Processes: IC ++ and more*
- (Biology)
- Dedicated CAD
- “Dedicated” packaging

MEMS ↔ IC

Many Similarities as well as Differences

- Technology
- Design
- Testing/Reliability
- Applications
 - » How much “standardization” possible/desirable/feasible?

MEMS



IC

No unit cell

No single "front end" technology, 3D

Multidimensional Interaction space

Very Multidisciplinary

Generally low volume

Application specific → design & technology

Unit cell: transistor

CMOS, 2D

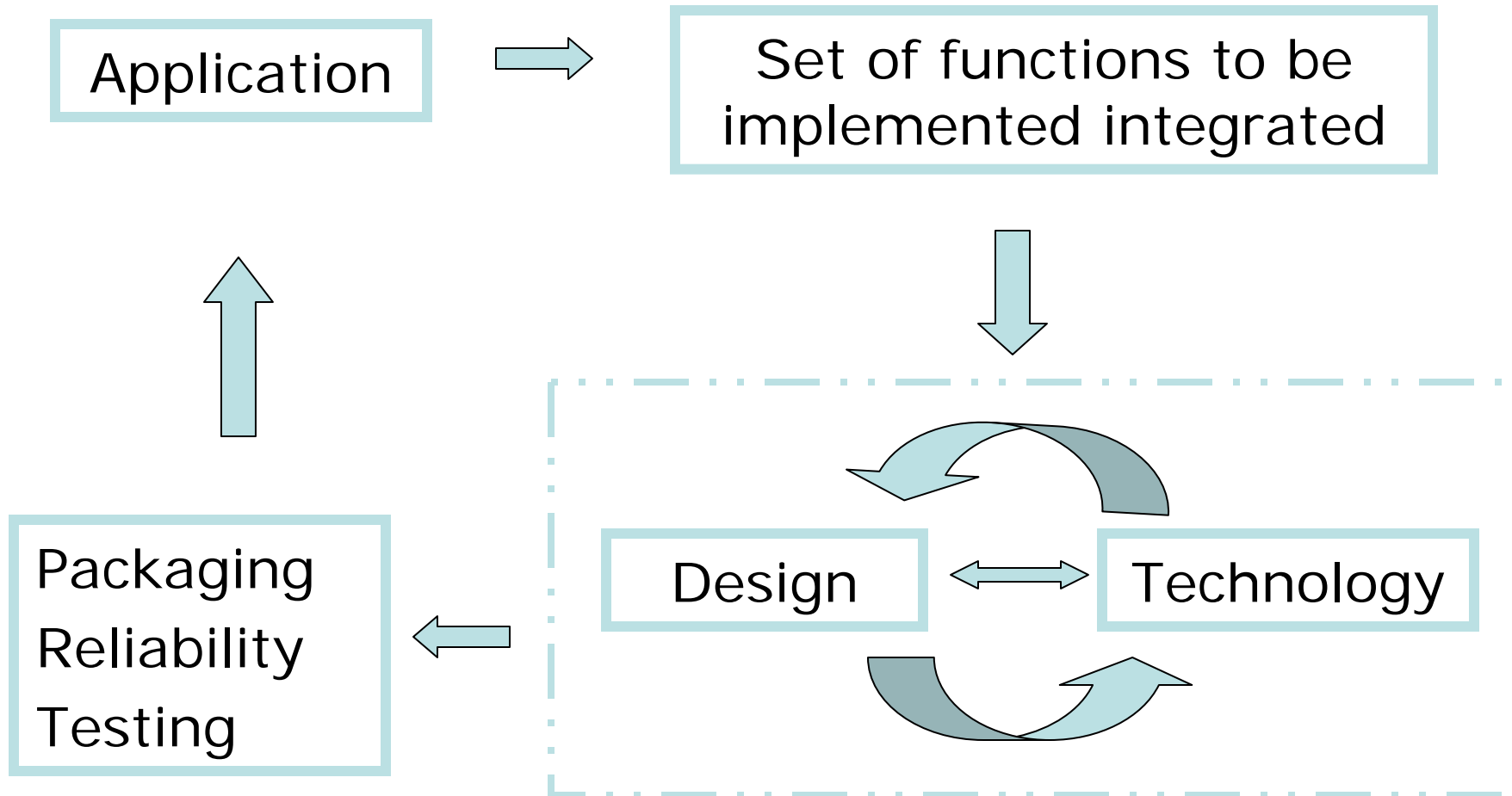
Electrical Connections

Physics & Engineering

Generally large volume

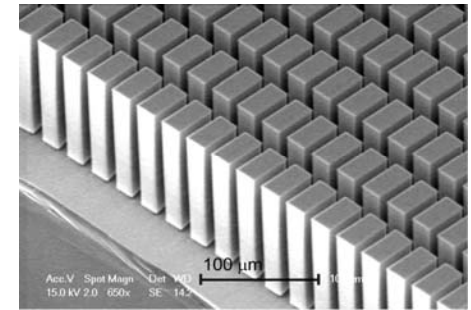
Application specific → design

MEMS

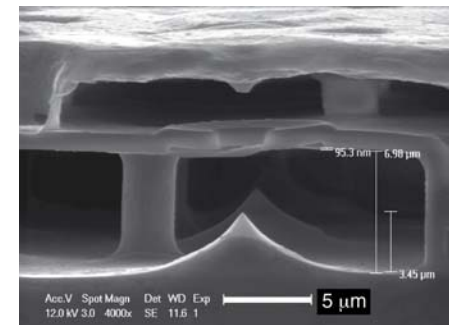


Technologies

- (Bi)CMOS
- Bulk Micromachining
- Surface Micromachining
- High-aspect ratio machining
- Wafer-to-wafer bonding
- Thin-film encapsulation
-



HAR fin-channel structure for microevaporator



SMM double cavity

3D micro/nano structuring

3D structures needed

to integrate specific functions

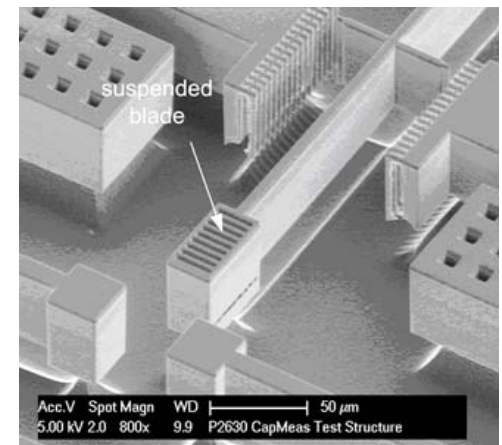
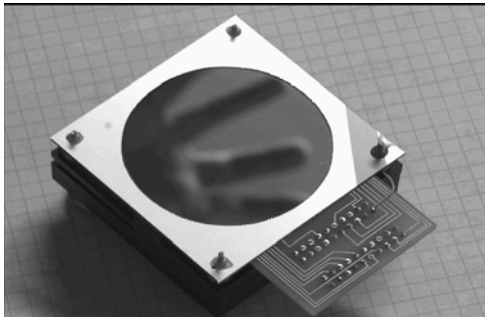
to enhance performance

to miniaturize complete system

“Main” Technology:

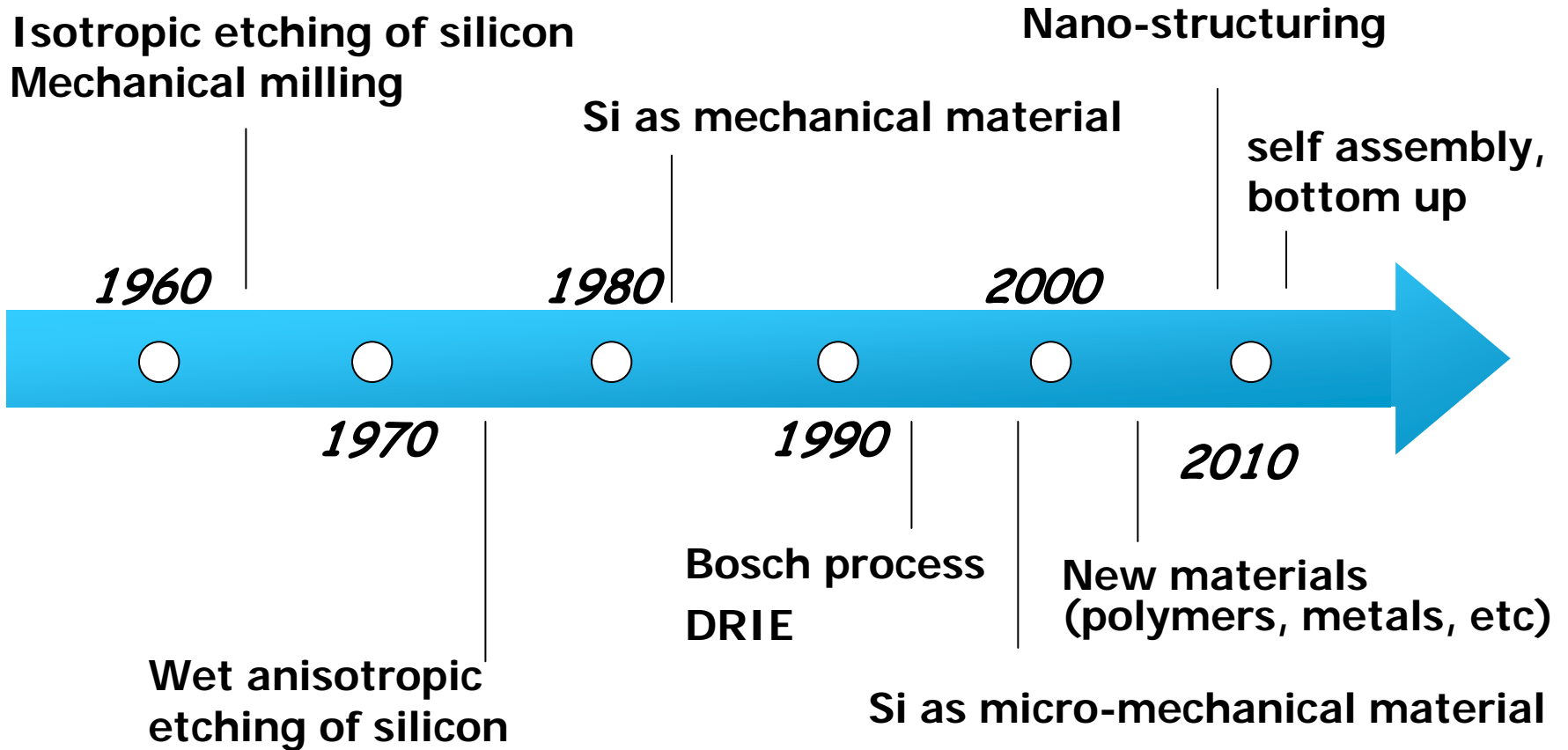
Bulk Micromachining

Surface Micromachining



Silicon Bulk Micromachining

... >40 years of development....



Silicon Surface Micromachining

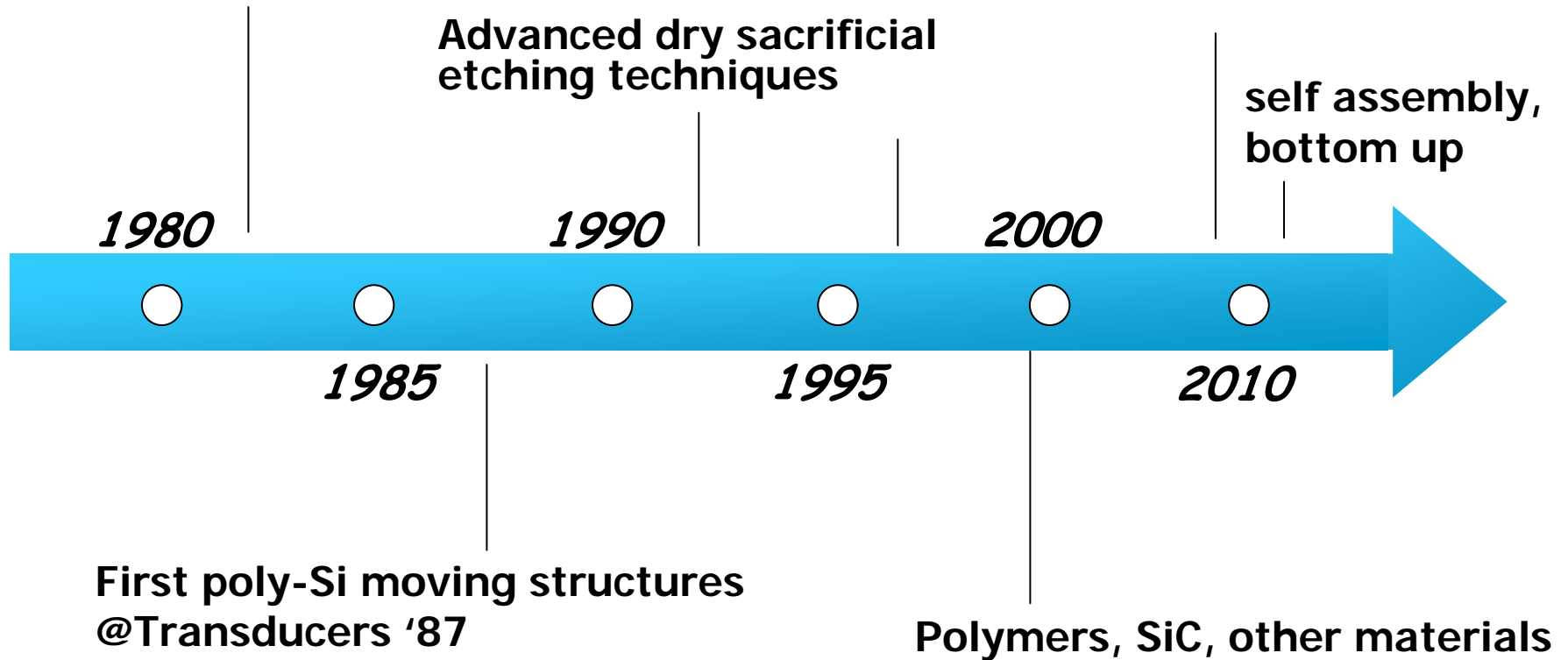
... > 25 years of development.....

Thin film deposition & etching techniques

Nano-structuring

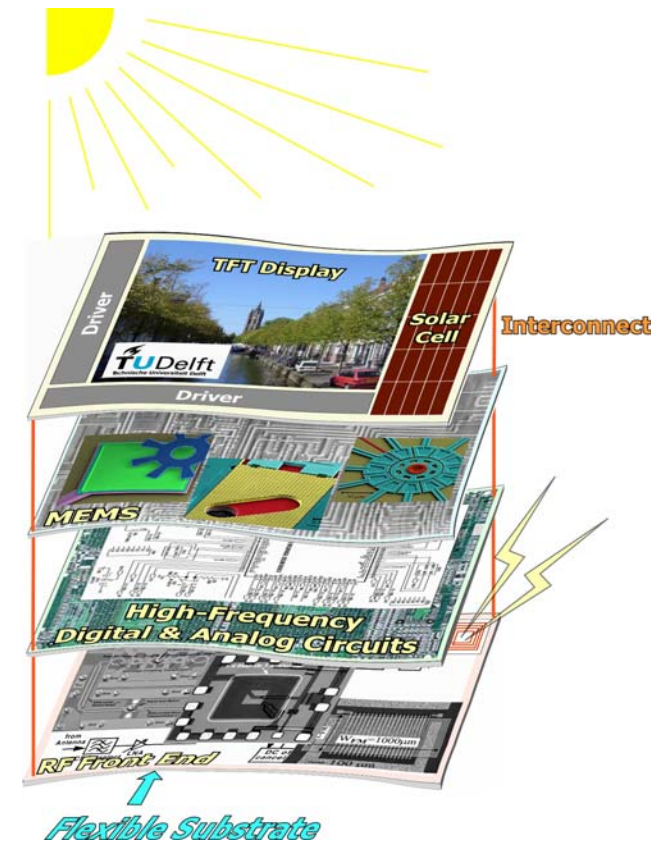
Advanced dry sacrificial etching techniques

self assembly, bottom up



Technology Trends

- Top down & Bottom up
BMM & SMM → "merge"
- Functional multi-layers
heterogeneous integration
- System approach
- Harsh environment
SiC, Diamond, Graphene
- Biocompatible
- "Flexible"



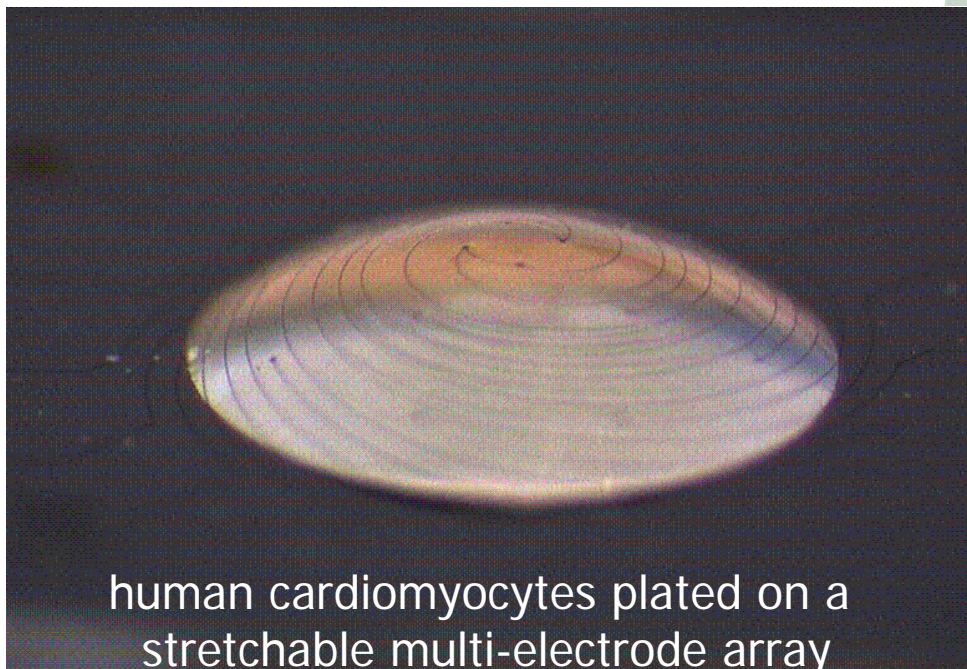
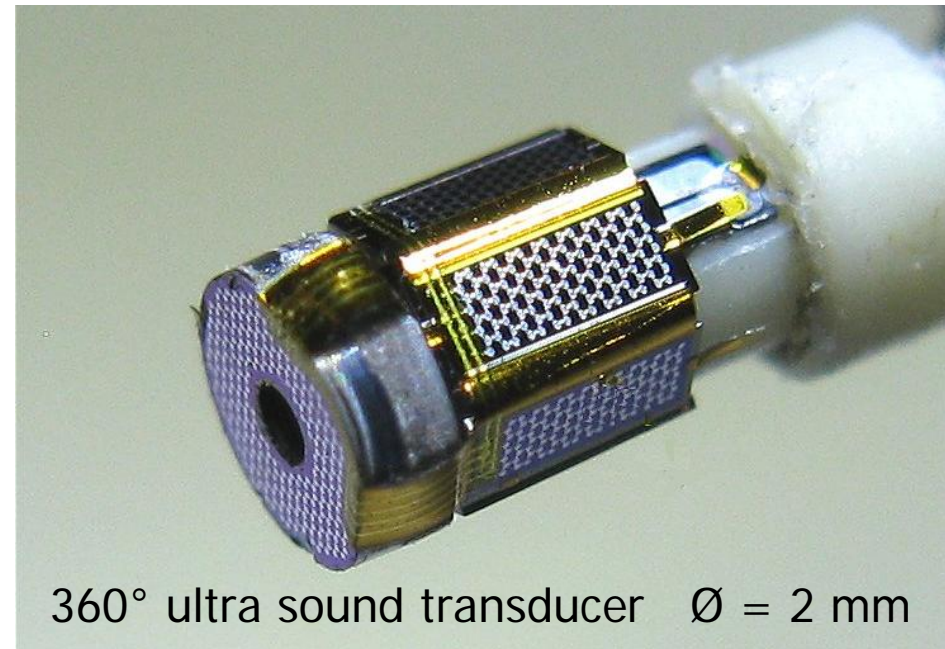
An example: "Living Chips"

Chips for the Living

bring electronics and sensors
to the tip of catheters and guidewires

cooperations:

Philips Medical Systems, St Jude Medical,
BmechE (3mE), Cardiovascular Biomechanics (TU/e)



Life on a Chip

integration of living cells on chips
as a functional layer

cooperations:

prof. C. Mummery (LUMC), Pluriomics (spin-off),
Philips Research

*prof. Ronald Dekker
TUD & Philips*

Design

Design of Device/Component
(package/system considerations)

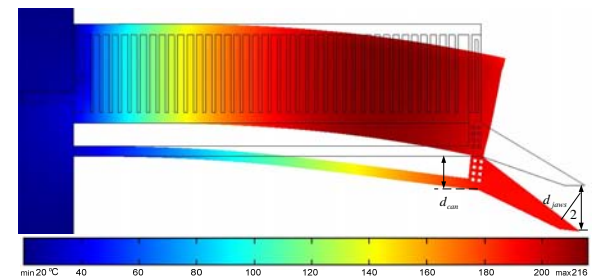
Modeling/Simulation:

specific features, several tools available

New device/new process

New device/existing process

Existing device/new process



Design Rules

“Design rules” for basic MEMS components
[mechanical structures and/or building blocks]

Membranes

Cantilevers

Beams

Comb Drives

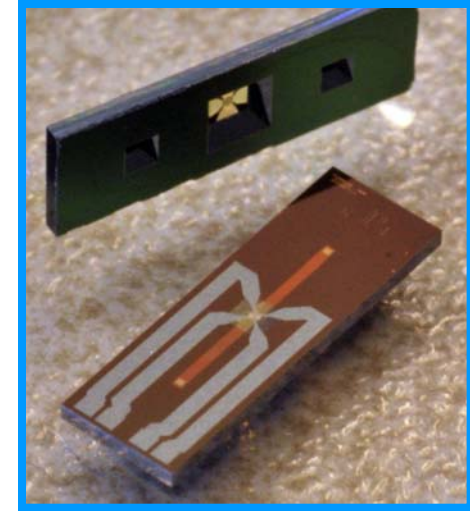
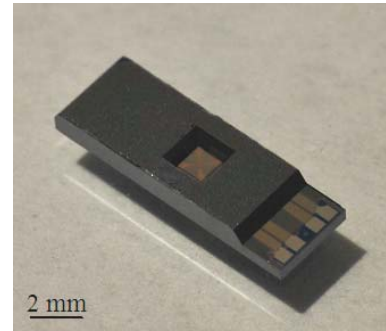
Piezoresistors, Electrodes, ...

Possible/necessary?

Strong link to technology & application

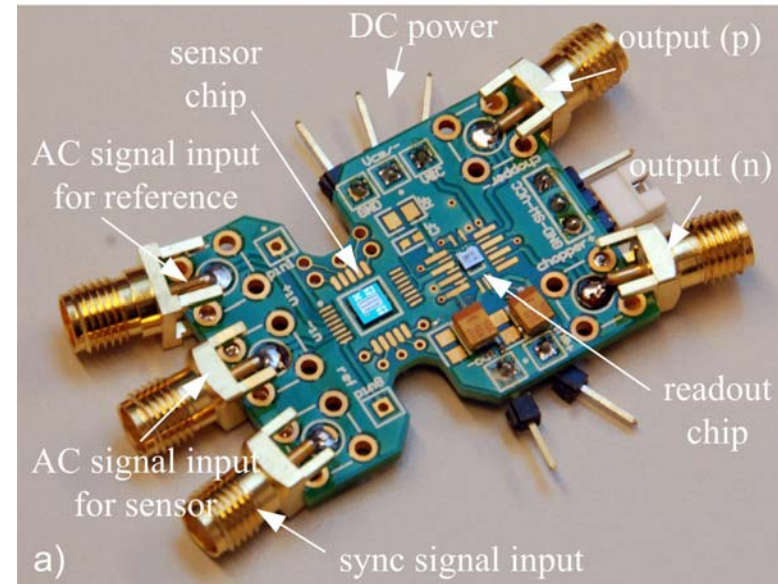
System Integration

- Monolithic vs Hybrid
- Wafer level
- Packaging level



System integration:

- ➔ controls performance,
- ➔ >70% costs,
- ➔ >90% size and reliability



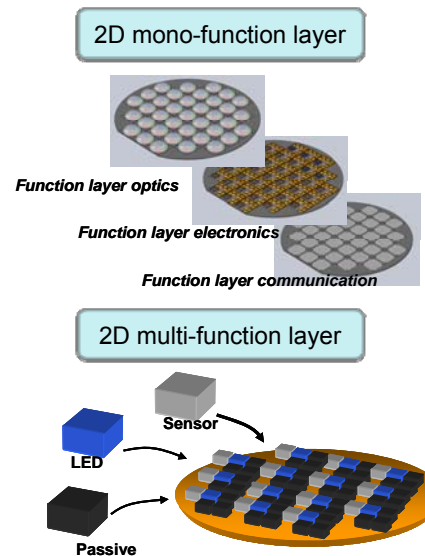
Wafer Level Integration

Wafer level, 3D, multi-function, smart and cost effective heterogeneous integration processes and technologies

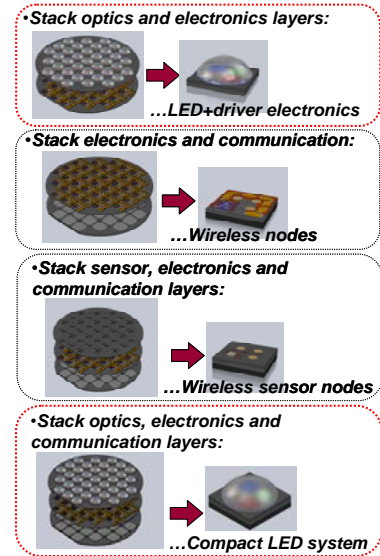
Research subjects

- ⚡ Polymer interposer technologies
- ⚡ Hybrid interposer stacking for multi-function wafers
- ⚡ 3D processes
- ⚡ Design for X (reliability, yield, testability, cost, etc.)

2D wafer integration



3D wafer integration

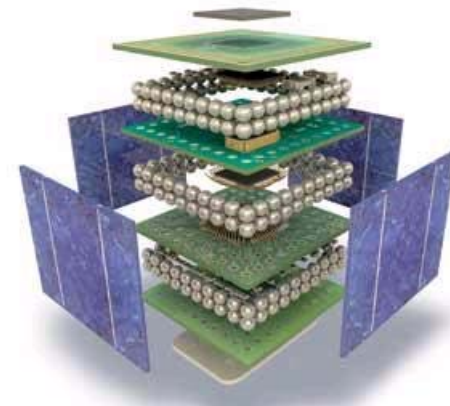
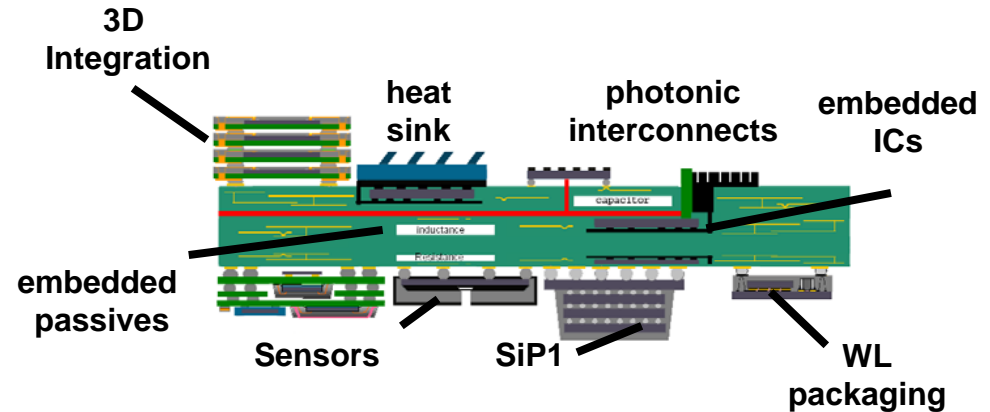


Package Level Integration (SiP)

Package level, 3D, multi-function, smart and cost effective heterogeneous integration processes and technologies

Research subjects

- ✦ Package architecture
- ✦ Integration processes for multi-functional modules & devices
- ✦ 3D and novel interconnect
- ✦ Design for X (reliability, yield, testability, green, etc.)
- ✦ Cost model



G.Q.Zhang, TUD & Philips

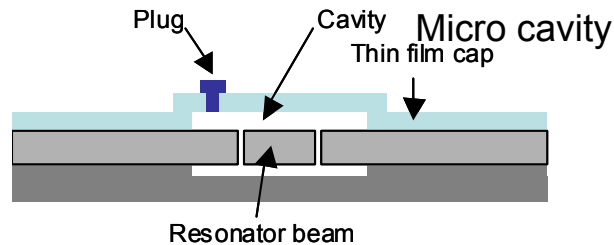
An example

- Thin film encapsulation for MEMS
 - Design for reliability
 - Mechanical design and modeling
 - IC compatible fabrication process
 - “pre-packaging” at wafer level

Design for Reliability of MEMS Packages

Motivations

- During MEMS design assembly and packaging influences on micro cavities should be considered as they can threaten the product or influence the performance.



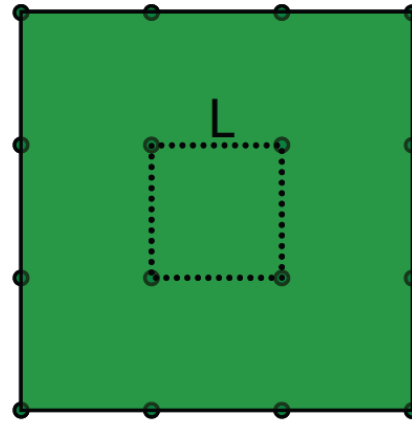
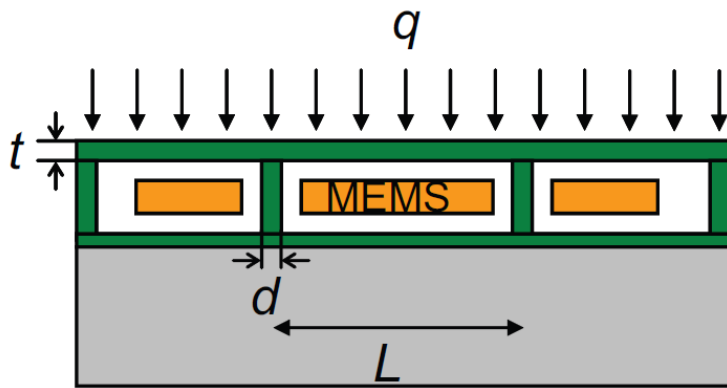
Objectives

- Develop predictive models to estimate weak spots in the design
- Find common failure modes of micro cavities
 - during manufacturing
 - during lifetime

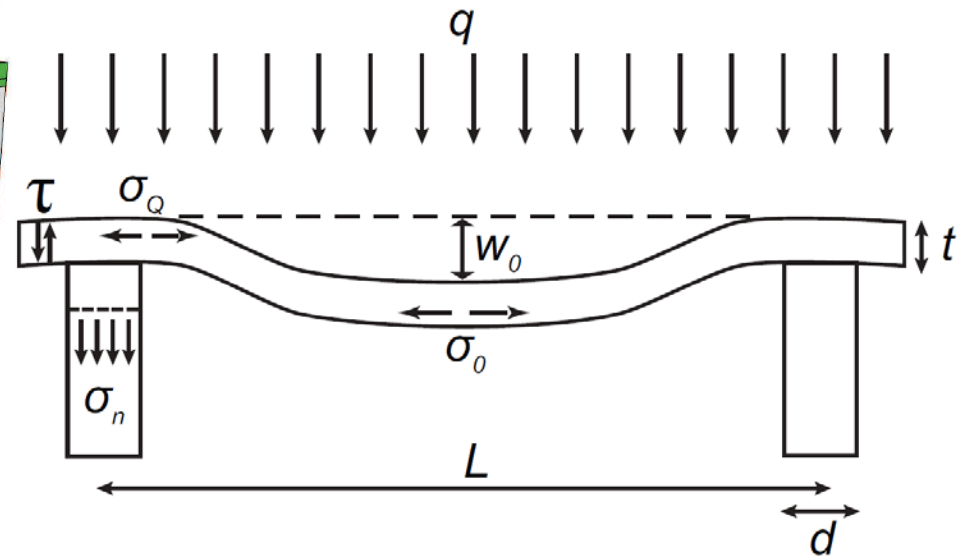
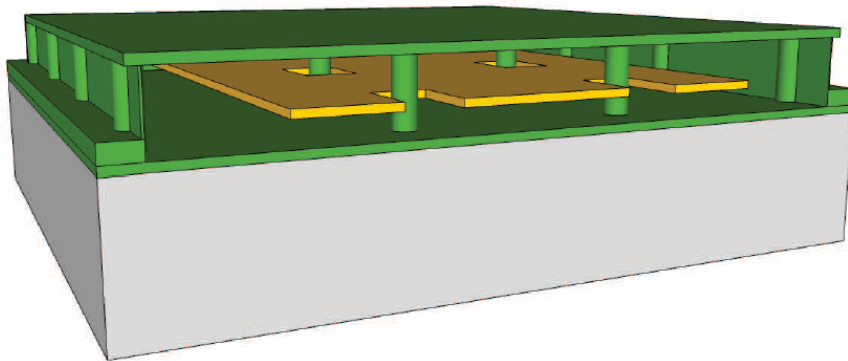
Approach

- Combined experimental – modeling approach
 - Experimental determination of failure mode
 - Modeling of failure
 - Proposal of geometry / process adjustments

Mechanical Design of Thin Film Encapsulation

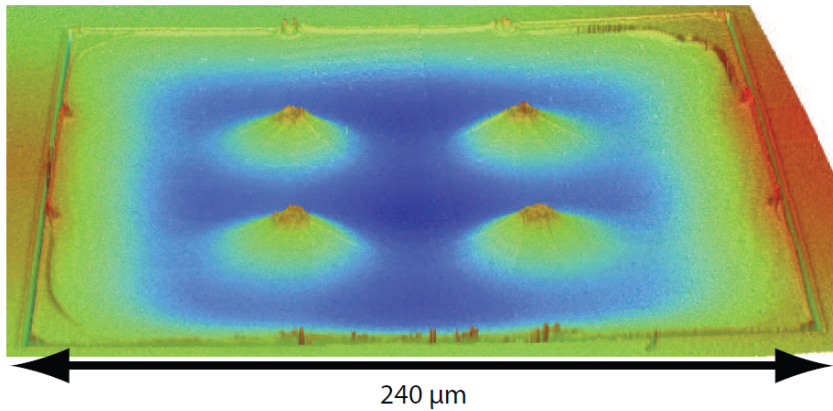
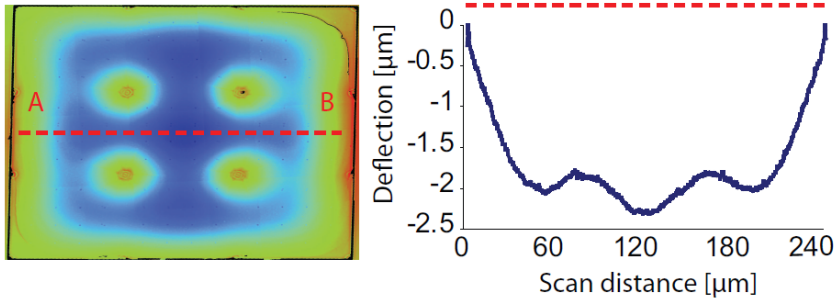


Thin-film package geometry consisting of a square plate with supporting columns

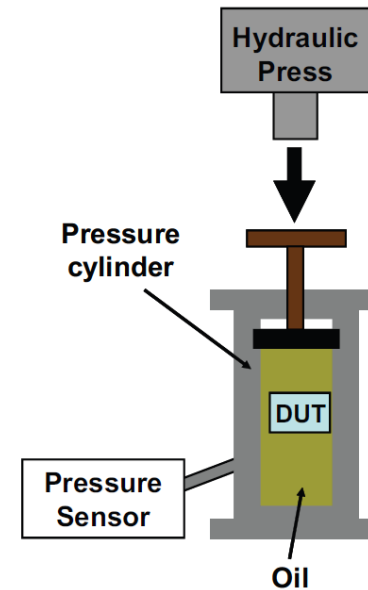


F.Santagata et al., TUDelft

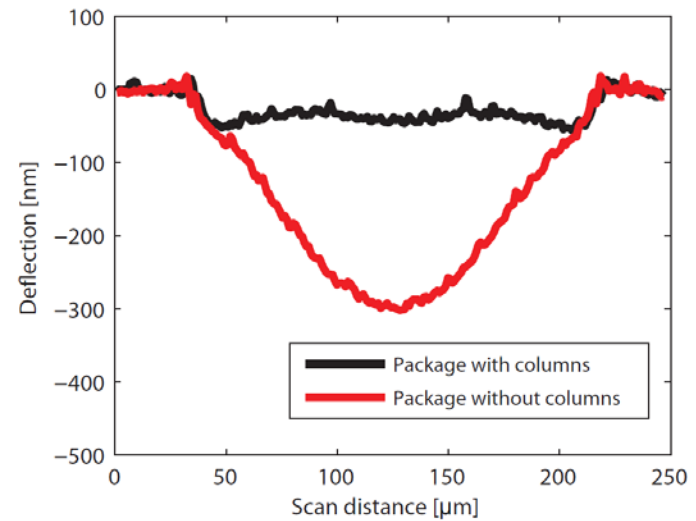
Stress components and the deflection of the capping layer taken into account in the mechanical model.



3D imaging of the packages by optical profilometry after loading. The cap deflects and is stuck to the bottom of the package.

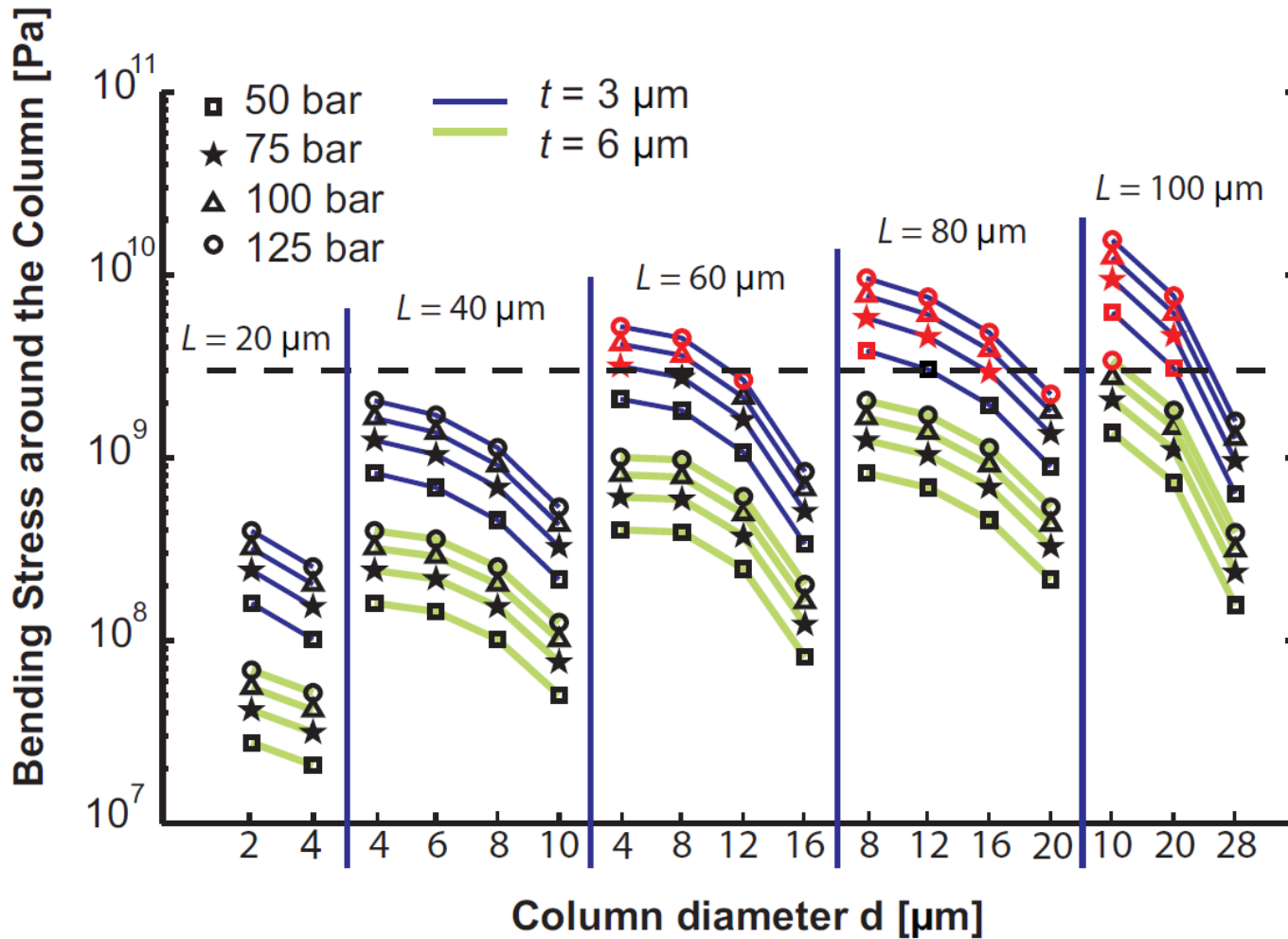


Sketch of the setup for the pressure test



Deflection under 1 bar. Comparison between two square packages (180 μm side length) with and without columns (4 μm diameter). The deflection of the package with no columns is too large for many applications.

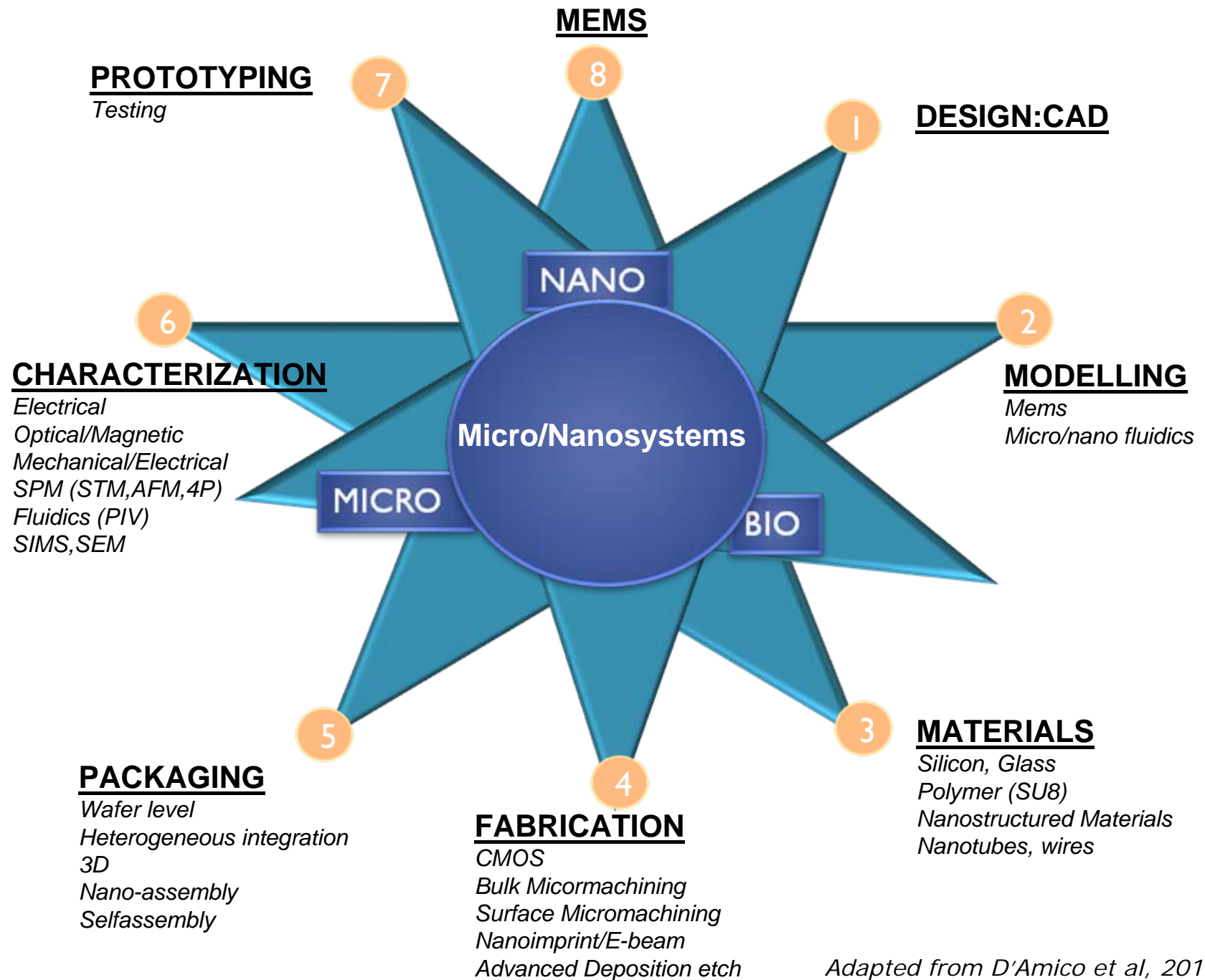
Hydrostatic pressure test



The red markers represent the broken packages.

Not broken | Broken

From idea to Product



Adapted from D'Amico et al, 2011

Challenges

- Miniaturization: size matters
- Integration: manage complexity
- New technologies: acceptance
- Autonomous: long life
- New applications: more functionality

Challenges

- Miniaturization:
 - Technology advances
 - Design tools
 - Simulation programs

Challenges

- Integration: manage complexity
 - Monolithic vs heterogeneous
 - Performance vs cost vs volume
- ➔ "user" wants a system!

Challenges

- New technologies
 - Needed to integrate new functionalities
 - Reliability
 - “multiple” applicability

Challenges

- Design ↔ Technology
 - Path to “generic” process(es)/standardization
 - Possibility and impossibility of a library
- Integration & Reliability
- Sub-domains:
 - Automotive
 - Bio/medical
 - CE and Mobile

Concluding Remarks

- **MEMS** development has come through fundamental research with an eye for the application.
- **Micro and nano technologies** advances offer many opportunities for improved performance and reduced costs in a wide range of industries.
- Emphasis is on improved functionality and reducing the size of the **system** rather than reduced size of individual components.
- **Scaling** of components should only be done where functional benefits can be obtained.
- Many applications require a **multi-disciplinary** approach
- **Health, Environment** and **Energy**: main application area